PATENT APPLICATION CROUP TOO TOO

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Masatake NAKANO et al.

Application No.: 09/857,569

Filed: June 7, 2001

Docket No.: 109716

METHOD FOR PRODUCING BONDING WAFER AND BONDING WAFER For:

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the reference(s) listed on the attached PTO-1449. Unless otherwise indicated herein, one copy of each reference is attached. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the reference(s) be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- M This Information Disclosure Statement is being filed (a) within three months of the U.S. filing date of this non-CPA application, OR (b) before the mailing date of a first Office Action on the merits in the present application. No certification or fee is required.
- M The references were cited in a counterpart foreign application. An English 2. language version of the foreign search report is attached for the Examiner's information.
- \bowtie An English-language Abstract of the non-English language reference No. 2 is attached hereto.

Respectfully submitted,

William P. Berridge Registration No. 30,024

Thomas J. Pardini Registration No. 30,411

WPB:TJP/tmw

Date: July 15, 2003

OLIFF & BERRIDGE, PLC P.O. Box 19928 Alexandria, Virginia 22320 Telephone: (703) 836-6400

DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461



SUPPLEMENTARY EUROPEAN SEARCH REPORT

Application Number EP 00 96 3000

	DOCUMENTS CONSIL			Dot-	01.4001814.1814.1		
Category	Citation of document with of relevant par		priate,	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.CI.7)		
Υ	BRUEL M ET AL: "S ON INSULATOR MATER HYDROGEN IMPLANTAT	IAL TECHNOLOGY	BASED ON	1-7	H01L27/12 H01L21/762		
	JAPANESE JOURNAL O PUBLICATION OFFICE APPLIED PHYSICS. T	F APPLIED PHYS JAPANESE JOUR	ICS,	,	JU RECK		
	vol. 36, no. 3B, P 1 March 1997 (1997 1636-1641, XP00070 ISSN: 0021-4922	-03-01), pages			SPOUD TOO		
	* page 1639, left- line 31; figure 1		ine 29 -		00		
Y	US 5 494 849 A (BA) 27 February 1996 (L)	1-4,7			
X	* column 4, line 4		igures 1-7	8,9			
Υ	EP 0 444 942 A (SH: 4 September 1991 (1991-09-04)		1,2,5,6			
-	* column 4, line 44 figures 1-7 *	4 - column 7,	line 2;		TECHNICAL FIELDS SEARCHED (Int.Cl.7)		
X				8,9	H01L		
	PATENT ABSTRACTS OF vol. 1999, no. 04, 30 April 1999 (1999 & JP 11 026336 A (\$ 29 January 1999 (19 * abstract *	9-04-30) SUMITOMO METAL	1-9				
į	EP 0 451 993 A (SHI 16 October 1991 (19 * figures 1-3 *		I KK)	1-9	·		
			٠				
				*			
	The supplementary search reposet of claims valid and available	rt has been based on ti at the start of the searc	ne last ch.				
	Place of search	Date of comple	ition of the search		Examiner		
MUNICH		20 May	2003	Göt:	cz, A		
CATEGORY OF CITED DOCUMENTS X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category		ther E	T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons				
A : techr O : non-	ological background written disclosure nediate document	••			, corresponding		

2

ANNEX TO THE EUROPEAN SEARCH REPORT ON EUROPEAN PATENT APPLICATION NO.

EP 00 96 3000

This annex lists the patent family members relating to the patent documents cited in the above-mentioned European search report. The members are as contained in the European Patent Office EDP file on The European Patent Office is in no way liable for these particulars which are merely given for the purpose of information.

20-05-2003

Patent document cited in search report			Publication date		Patent family member(s)		Publication date	
US	5494849	A	27-02-1996	EP JP WO US	0815592 11502674 9629732 5937312	T Al	07-01-1998 02-03-1999 26-09-1996 10-08-1999	
EP	0444942	А	04-09-1991	JP JP JP DE DE EP US	7019737 69127841	A B D1 T2 A1	08-12-1995 08-11-1991 06-03-1995 13-11-1997 26-03-1998 04-09-1991 23-08-1994	
JP	11026336	Α	29-01-1999	NONE				
EP	0451993	A	16-10-1991	JP JP JP EP US	1915942 3280538 6036413 0451993 5152857	A B A2	23-03-1995 11-12-1991 11-05-1994 16-10-1991 06-10-1992	

Sheet 1 of 1

Form PTO-144 (REV. 8-83)				ATTY DOCKET NO. 109716			APPLICATION NO. 09/857,569		
INFO	ORMATIO	ON DISCLOSURE STATEMENT				Ji.	JEO.		
(Use several sheets if necessary)					APPLICANTS Masatake NAKANO et al.				
					DATE 001	APPLICATION NO. 09/857,569 APPLICATION NO. 09/857,569 APPLICATION NO. 09/857,569			
		U.S. I	PAT	ENT DOCU	JMENTS				
EXAMINER INITIAL		DOCUMENT NUMBER		DATE	NAME			SUB CLASS	
_	1	5,494,849	02/	27/1996	7/1996 Iyer et al.				
·								<u>.</u>	
								. 1.	
		FOREIG	N P.	ATENT DO	OCUMENTS		1		
		DOCUMENT NUMBER		DATE COUNTRY		CLASS		SUB CLASS	
	2	JP A 11-026336 (abstract only)	01/	29/1999	Japan				
	3	EP 0 451 993 A2	10/	16/1991	Europe				
								* * *	
		OTHER DOCUMENTS (Inc	ludi	ng Author,	Title, Date, Pertinent Pages, etc	.)			
	M. Bruel et al., "Smart-Cut: A New Silicon On Insulator Material Technology Based on Hydrogen Implantation and Wafe Bonding", Jpn. J. Appl. Phys., Vol 36, 1997, pp 1636-1641								
					·			·	
1									
EXAMINER					DA	TE CONSID	ERED		
Examiner:		f citation considered, whether or not citance and not considered. Include copy o					hrough citati	on if not in	

Date: July 15, 2003